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184-P057D1  
(f/k/a D900D/1368D)

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PATENT  
U.S. Ser. No. 10/079,775

\$2823  
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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Plat, et al.  
Serial No.: 10/079,775  
Conf. No.: 9123  
Filed: February 19, 2002  
Title: Method and System for Reducing ARC layer Removal During  
Removal of Photoresist  
Art Group: 2823  
Examiner: Lee, Hsien Ming.

Mail Stop: Fee Amendment  
Commissioner of Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

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*Michael P. Adams*  
Signature

Michael P. Adams  
Printed Name

5/20/03  
Date

**RESPONSE TO OFFICE ACTION**

In response to the Office Action mailed November 20, 2002 (Paper 3), Applicants respectfully request that the Examiner reconsider the rejection of the claims in view of the amendments and comments set forth herein.

In the Specification:

Please replace the current Title with:

WSM Docket No.  
184-P057D1  
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